





Example 5.2

Consider an nMOS transistor fabricated in a 0.18µm process with L=0.18µm and W=2um. The process technology is specified to have C_{ox} =8.6fF/µm², µ_n=450cm²/V·s, and V_{th}=0.5V.

- a) Find V_{GS} and V_{DS} that result in the MOSFET operating at the edge of saturation with $I_D = 100 \ \mu A$.
- b) If V_{GS} is kept constant, find V_{DS} that results in $I_D = 50 \mu A$.
- c) To investigate the use of the MOSFET as a linear amplifier, let it be operating in saturation with V_{DS} =0.3V. Find the change in i_D resulting from v_{GS} changing from 0.7V by +0.01V and by -0.01V.

a) K_n=4.3mA

Exercise 5.5

An n-channel MOSFET operating with V_{ov} =0.5V exhibits a linear resistance r_{DS} =1k Ω when v_{DS} is very small.

- a) What is the value of the device trans-conductance parameter K_n ?
- b) Assuming $\lambda = 0$, what is the value of the current I_D obtained when v_{DS} is increased to 0.5V? And to 1V?
- c) Assuming an $\lambda = 0.1V^{-1}$, what is the value of the current I_D obtained when v_{DS} is increased to 0.5V? And to 1V?